



JPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of:

Suing-Jun LIM

Serial No. 10/809,857

Filed: March 26, 2004

For: METHOD OF A PHOTOLITHOGRAPHY
PROCESSING SYSTEM
(AS AMENDED)

Group Art Unit: 1756

Examiner: Christopher G. Young

Confirmation No.: 7580

Atty. Docket No. 242/120 DIV

AMENDMENT UNDER 37 C.F.R. § 1.111

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Va. 22313-1450

Sir:

INTRODUCTORY COMMENTS

In response to the Office action dated August 18, 2004, the following amendments and remarks are respectfully submitted in connection with the above-identified application:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in a listing of claims, which begins on page 3 of this paper.

Remarks begin on page 6 of this paper.

A replacement Abstract of the Disclosure is attached at page 12 of this paper.